



## [WeF2] Materials and Processing for Advanced Packaging

<b>Session Date</b>	November 12 (Wed.), 2025
<b>Session Time</b>	14:10–15:50
<b>Session Room</b>	Room F (Panorama Room, 16F)
<b>Session Chair</b>	Prof. Ah-Young Park (Univ. of Seoul, Korea)

### [WeF2-1] [Invited] 14:10–14:30

#### Development of an Eco-Friendly Photoresist Stripper for Advanced Semiconductor Packaging Processes

Bo Yeon Lee, Sangseung Park, Seungeun Lee, Ga Young Kim, Seok Jin Hong, and Jung Shik Heo (ENF Technology Co., Ltd., Korea)

### [WeF2-2] [Invited] 14:30–14:50

#### FINE Cut and FINE Forming (TGV) of HBM4, Glass Core and Interposer

Seak-Joon Lee (ITI, Korea)

### [WeF2-3] [Invited] 14:50–15:10

#### Glass Package Substrates for High-Performance Chiplet Systems

Jimin Kwon (UNIST, Korea)

### [WeF2-4] [Invited] 15:10–15:30

#### Bonding Strength and Fracture Behavior in Patterned Cu–SiO<sub>2</sub> Hybrid Interfaces

Ah-Young Park (Univ. of Seoul, Korea), Hakyung Jeong (KIMM, Korea), and Kyung-Ho Park (KANC, Korea)

### [WeF2-5] [Invited] 15:30–15:50

#### Development of Optical Interconnection Core Technologies for Implementation and Reliability Enhancement of Co-Packaged Optics

Hongyun So, Keuntae Baek, and Animesh Sinha (Hanyang Univ., Korea)